

## N THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Group Art Unit: 1732

Brian W. Baird, Michael J. Wolfe, Richard S. Harris, Kevin P. Fahey, Lian-Cheng Zou, and Thomas R. McNeil

Application No. 10/017,497

Filed: December 14, 2001

For: **ULTRAVIOLET LASER ABLATIVE** 

PATTERNING OF MICROSTRUCTURES

IN SEMICONDUCTORS

Date: February 4, 2005

Examiner: Dr. Stefan Staicovici

I HEREBY CERTIFY THAT THIS CORRESPONDENCE IS BEING DEPOSITED WITH THE UNITED STATES POSTAL SERVICE AS FIRST CLASS MAIL IN AN **ENVELOPE ADDRESSED TO:** 

COMMISSIONER FOR PATENTS

ALEXANDRIA, VA 22313

Connie

## PETITION FOR EXTENSION OF TIME UNDER 37 CFR § 1.136(a)

## TO THE COMMISSIONER FOR PATENTS:

Applicants' attorney/agent hereby petitions that the time for response to the October 4, 2004 Office action, having a January 4, 2005 expiration date, be extended for a period of one month to February 4, 2005.

The enclosed check for the total fees includes the one-month time extension fee.

Respectfully submitted,

Brian W. Baird, Michael J. Wolfe, Richard S. Harris, Kevin P. Fahey,

Lian-Cheng Zou, and Thomas R. McNeil

02/10/2005 CCHAU1

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